

METALLURGICAL MICROSCOPE



This Microscope is used in IT Industry for Large Area Integrated Circuit, Wafer Observation and Inspection.

Specifications

- Trinocular Head 30°
- Extra Wide Field Eyepiece EW10X / 22
- INFINITIVE PLAN Achromatic Objectives:
 - 4X / 0.1 WD 25.4 mm
 - 10X / 0.25 WD 11 mm
 - 20X / 0.4 WD 6 mm
 - 40X / 0.6 WD 3.7 mm
- Quadruple Nosepiece
- Mechanical Stage: Size 300 mm × 268 mm, Movement 250 mm × 250 mm
- Coaxial Coarse and Fine Focusing Range: 24 mm
- Illumination: 200V or 110V / 6V 20W Halogen Lamp, Brightness Adjustable
- Filter: Blue, Green, Yellow, Ground Glass